

Supporting Information

Three-dimensional NiCo₂O₄/NiCo₂S₄ Hybrid Nanostructures on Ni-foam as High-performance Supercapacitor Electrode

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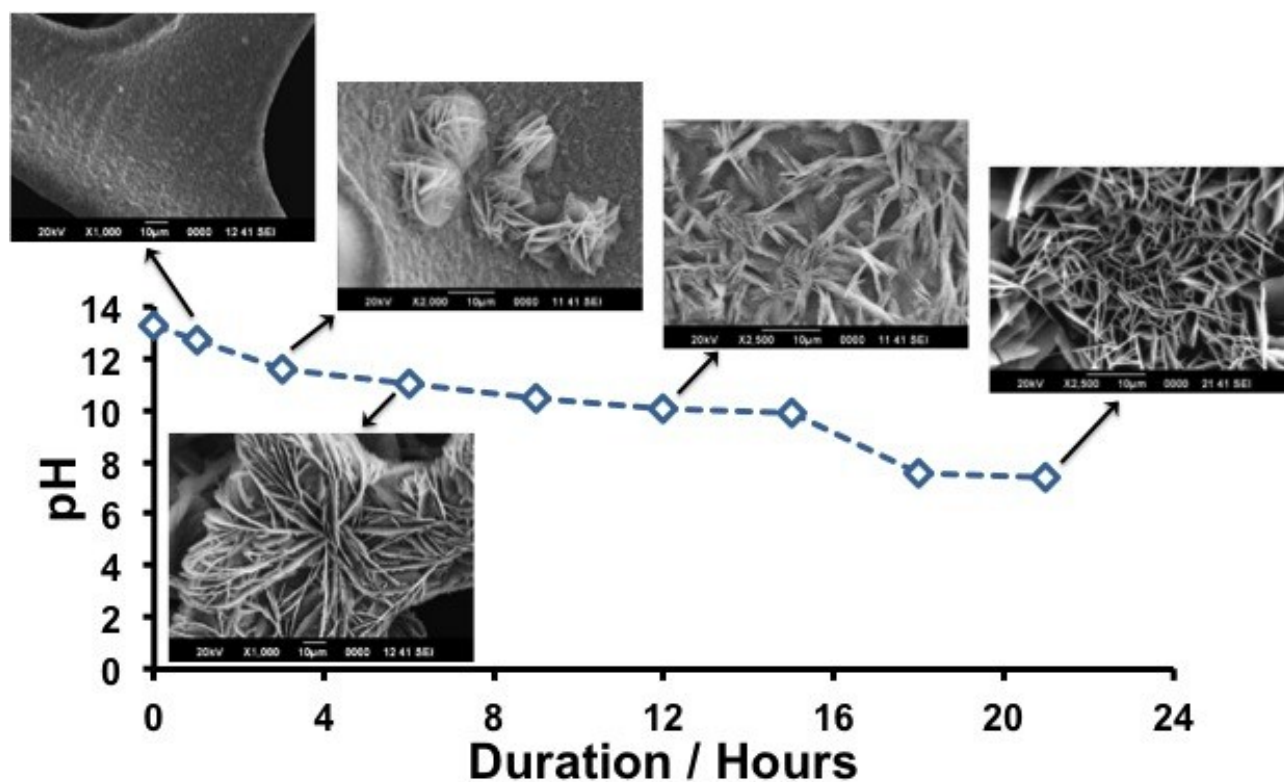


Figure S1: Growth process of NiCo-hydroxide precursor deposition on Ni-foam at different reaction durations and different pH.

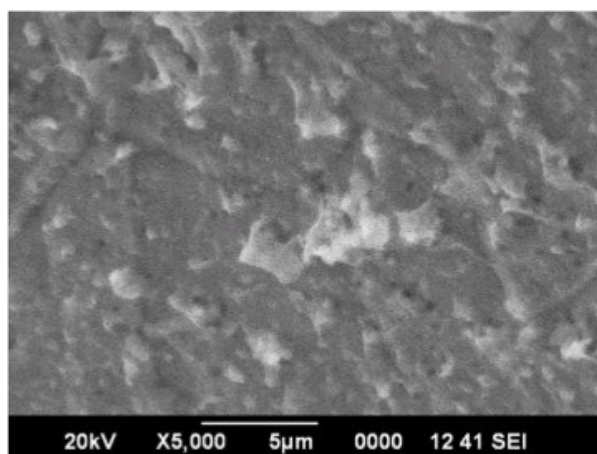


Figure S2: Deposition of NiCo-hydroxide precursor on Ni-foam at pH 11 adding few drops of ammonia.

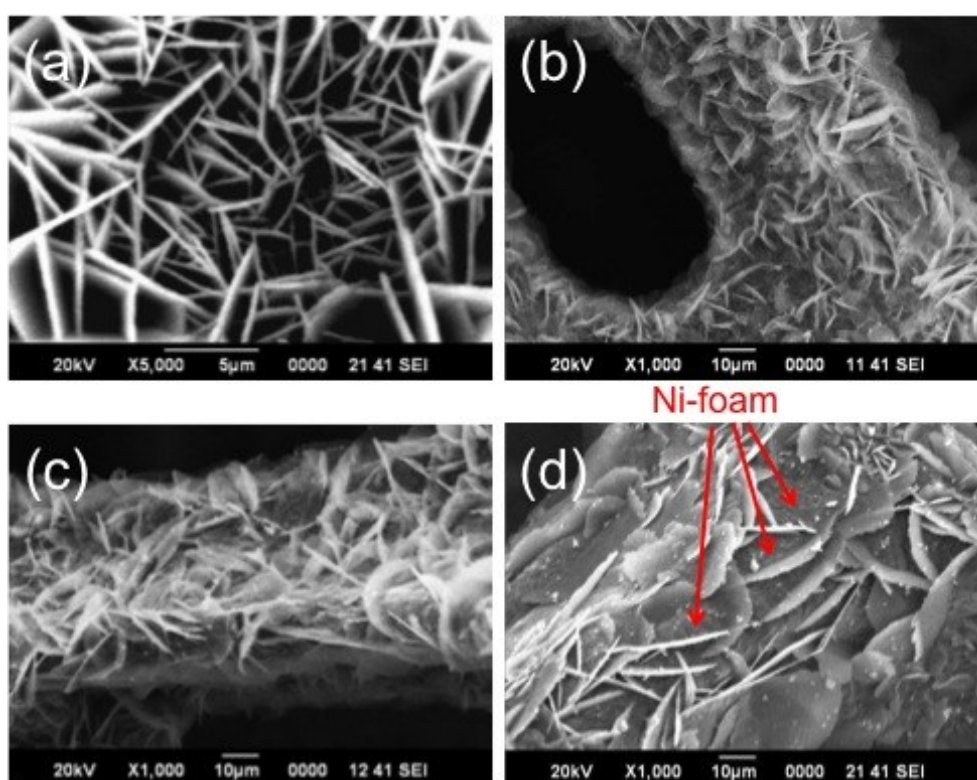


Figure S3: NiCo-hydroxide precursor deposition on Ni-foam at different ammonia : water ratios: (a) 50 : 0; (b) 40 : 10; (c) 30 : 20 and (d) 20 : 30.

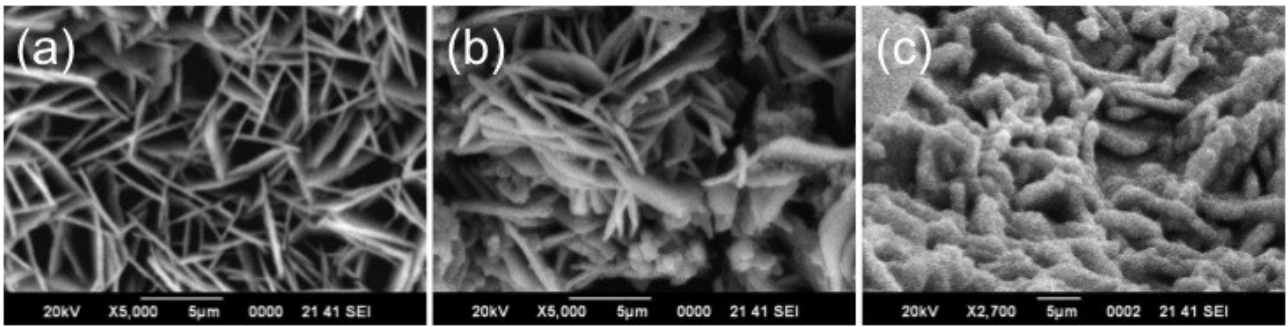


Figure S4: Variation of NiCo-hydroxide nanosheet thickness upon number of deposition: (a) Single deposition, (b) 3-times deposition and (c) 10-times deposition.

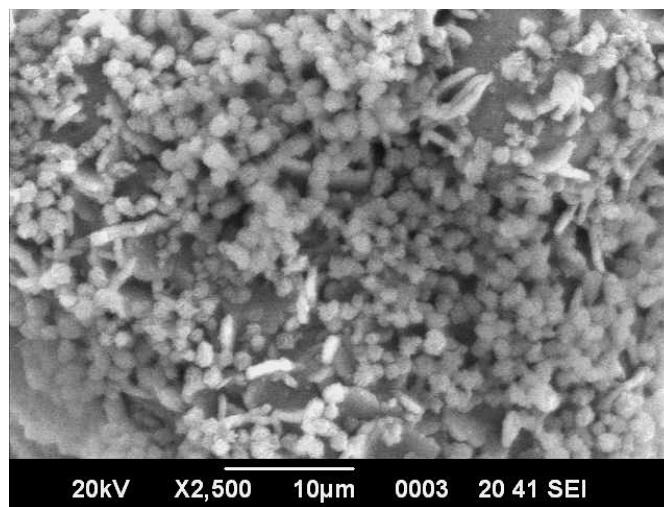


Figure S5: NiCo₂S₄ nanoflake balls deposited on NiCo₂O₄ nanosheets.

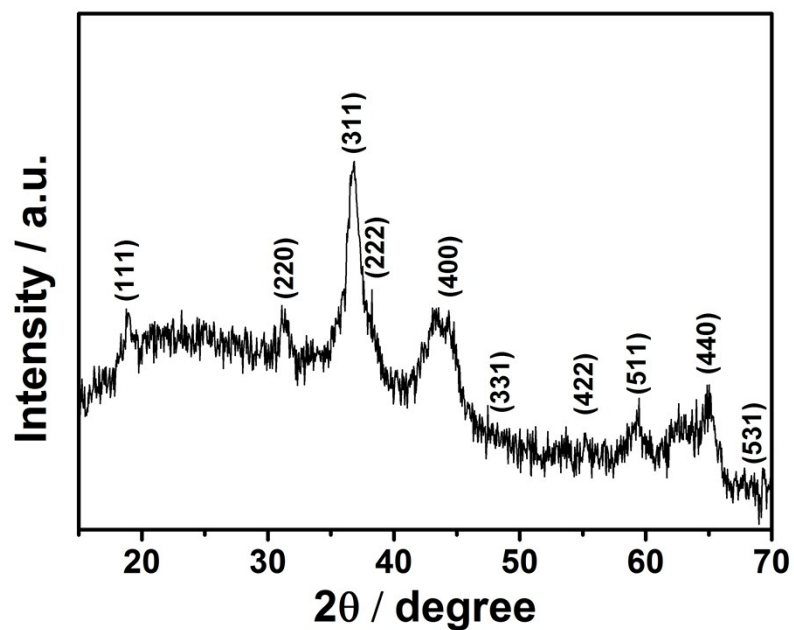


Figure S6: XRD pattern of NiCo₂O₄ nanosheets (JCPDS No. 20-0781) without Ni foam.

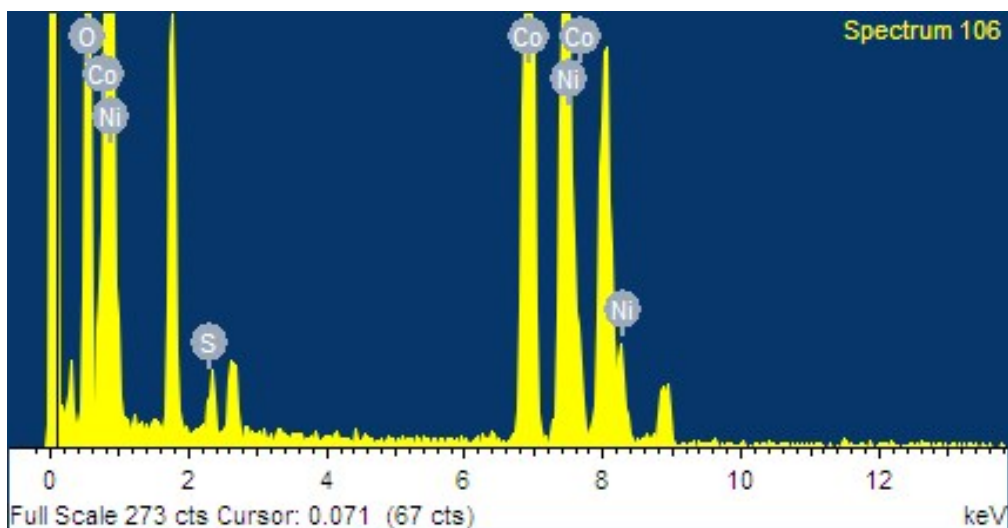


Figure S7: Energy dispersive x-ray analysis of NiCo₂O₄/NiCo₂S₄ nano hybrids.

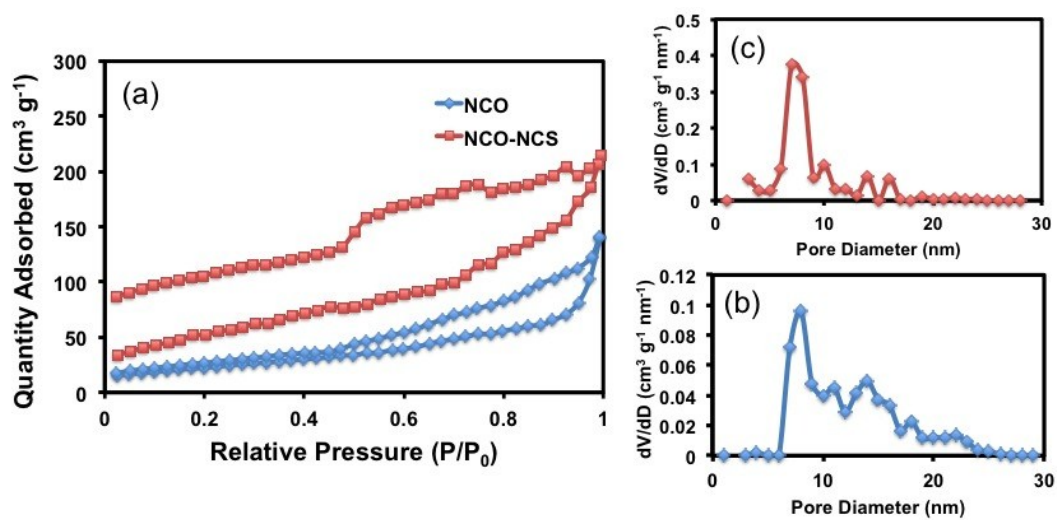


Figure S8: (a) N₂ adsorption–desorption isotherm of NCO and NCO-NCS and (b-c) BJH pore size distribution of NCO (b) and NCO-NCS (c).

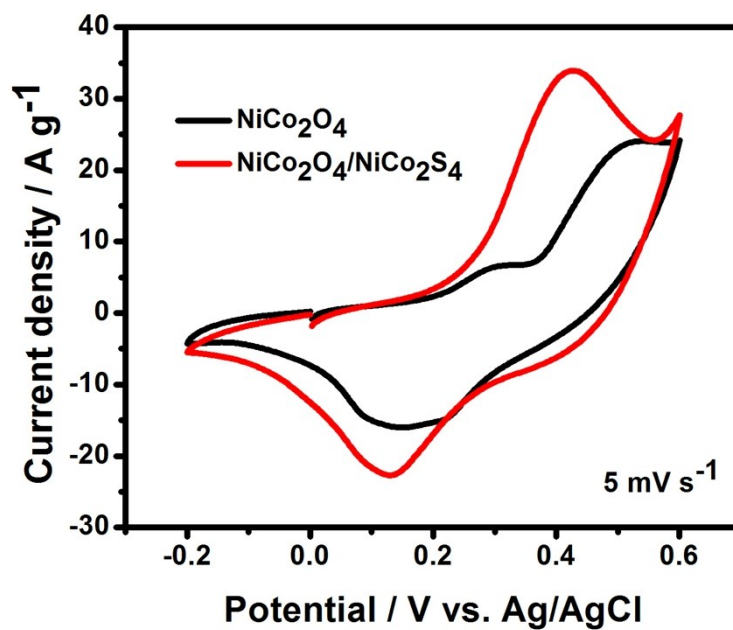


Figure S9: CV diagram of NiCo₂O₄ nanosheets and NiCo₂O₄/NiCo₂S₄ hybrid nanostructures at a scan rate 5 mV s⁻¹

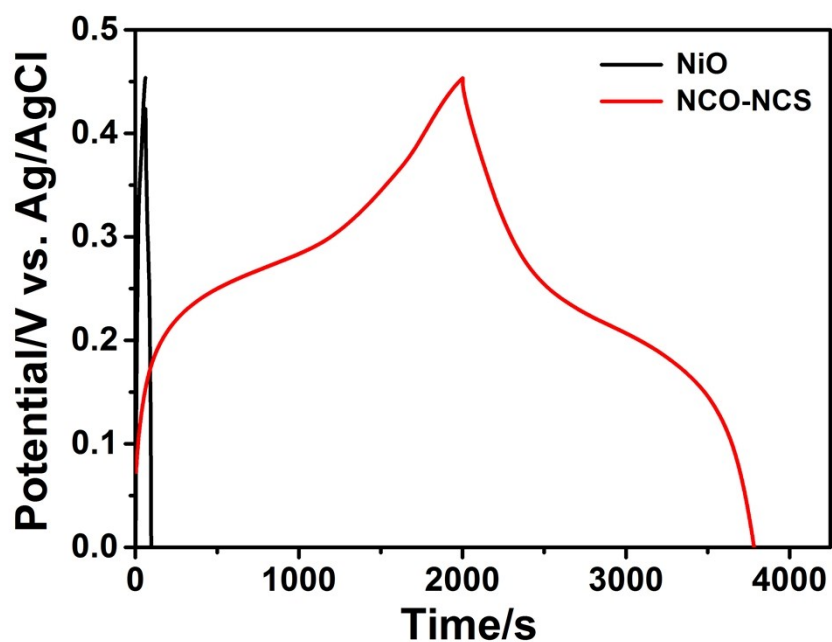


Figure S10: Charge-discharge profile of NiO (formed on Ni foam by annealing) and NiCo₂O₄/NiCo₂S₄ hybrid electrode at current density 1.33 mA cm⁻² showing negligible contribution of NiO (Areal capacitance $C_a = 0.106$ F cm⁻²) in the performance of hybrid nanostructure (Areal capacitance $C_a = 5.24$ F cm⁻²).

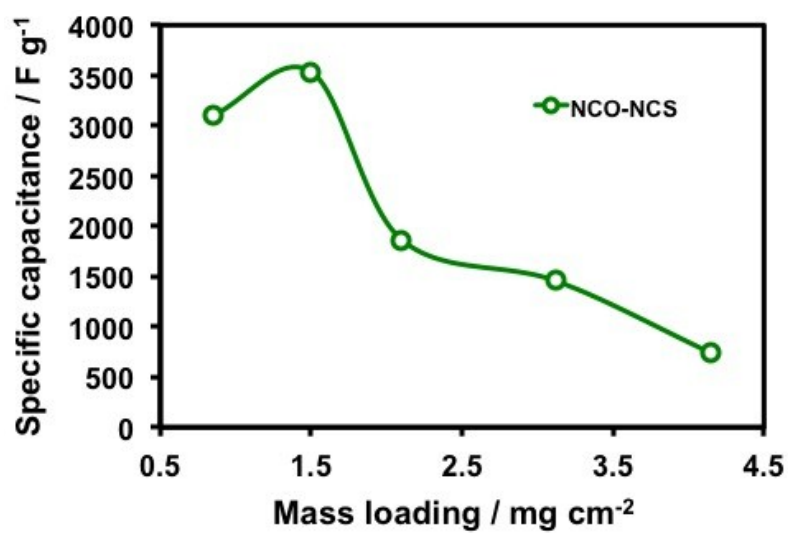


Figure S11: Specific capacitance (@ 1 A g^{-1}) as a function of mass loading for $\text{NiCo}_2\text{O}_4/\text{NiCo}_2\text{S}_4$ hybrid nanostructures on Ni foam.

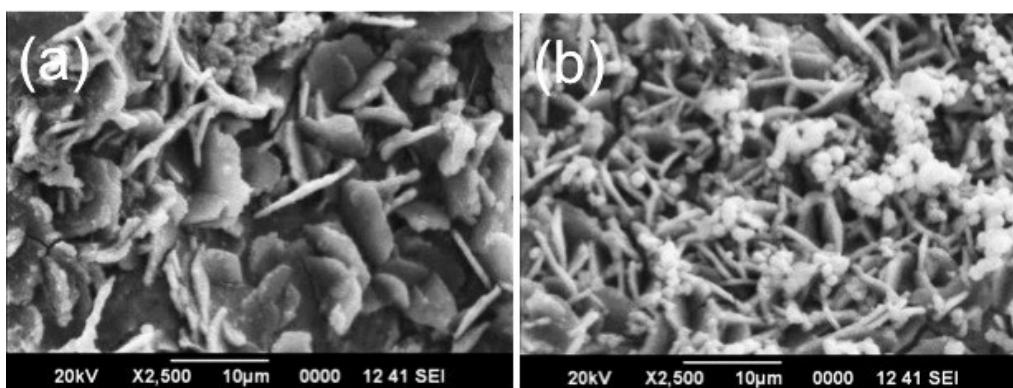


Figure S12: SEM images of (a) NCO and (b) NCO-NCS after stability tests of several thousand cycles.

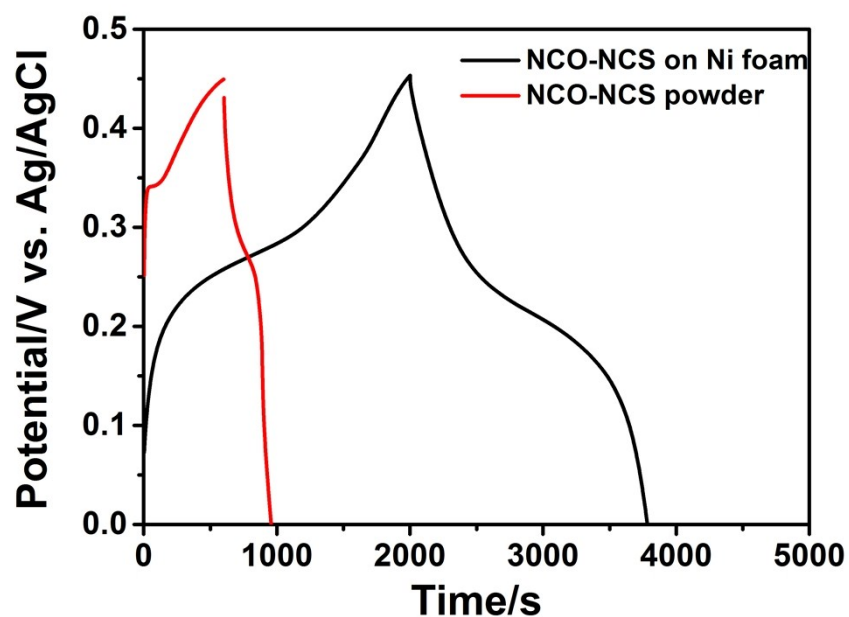


Figure S13: Charge-discharge profile comparison of physically mixed NiCo_2O_4 and NiCo_2S_4 in 3:1 ratio (791 F g^{-1} @ 1 A g^{-1}) and directly grown $\text{NiCo}_2\text{O}_4/\text{NiCo}_2\text{S}_4$ hybrid nanostructure on Ni foam (3542 F g^{-1} @ 0.9 A g^{-1}). Physically mixed NiCo_2O_4 and NiCo_2S_4 powder based electrode was fabricated by mixing 80% of sample with 10% PVDF and 10% C-black in NMP.

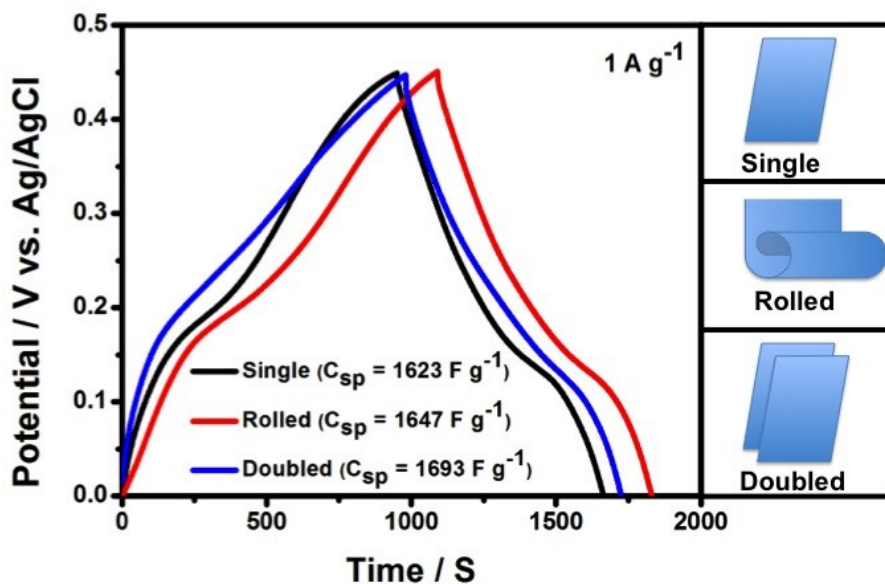


Figure S14: Flexibility test of $\text{NiCo}_2\text{O}_4/\text{NiCo}_2\text{S}_4$ hybrid electrode: Galvanostatic charge-discharge profile of 'single', 'rolled' and 'doubled' experiment at current density 1 A g^{-1} .

Table S1: Comparison of specific capacitance and capacity retention values of reported NiCo₂O₄ and NiCo₂S₄-based electrodes with the present work.

Electrode Material	Method	Specific capacitance (F g ⁻¹)	Current density (A g ⁻¹)	Capacity retention	Ref.
NiCo ₂ O ₄ nanosheets	Microwave	467	10	95% after 5000 cycles @10 A g ⁻¹	1
NiCo ₂ O ₄ nanotubes	Electrospinning technique	1647 1300	1 10	93.6% after 3000 cycles @10 A g ⁻¹	2
Urchin-like NiCo ₂ O ₄ nanostructures	Hydrothermal	1650 1348	1 15	90.8% after 2000 cycles @8 A g ⁻¹	3
NiCo ₂ O ₄ microstructure	Hydrothermal	700	10	78.7% after 5000 cycles @10 A g ⁻¹	4
NiCo ₂ O ₄ hollow sphere	Solvothermal	1141 862	1 10	94.7% after 4000 cycles @5 A g ⁻¹	5
NiCo ₂ S ₄ hollow spheres	Hydrothermal	1263	2	94% after 20000 cycles @10 A g ⁻¹	6
NiCo ₂ S ₄ hexagonal plates	Hydrothermal	1085 852	0.5 10	95.6% after 2000 cycles @10 A g ⁻¹	7
NiCo ₂ S ₄ ball-in-ball hollow spheres	Solvothermal	1036 760	1 10	87% after 2000 cycles @5 A g ⁻¹	8
NiCo ₂ O ₄ nanoneedle on Ni foam	Hydrothermal	2193 1490	1 10	72% after 2000 cycles @5 A g ⁻¹	9
NiCo ₂ O ₄ multiple hierarchical structures on Ni foam	Hydrothermal	2623 2121	1 10	94% after 3000 cycles @10 A g ⁻¹	10
NiCo ₂ O ₄ nanowires on C-Frame	Hydrothermal	1696 1231	1 8	88% after 2000 cycles @5 A g ⁻¹	11
NiCo ₂ O ₄ nanosheet on Ni foam	Co-electrodeposition	2010 1596	2 12	94% after 2300 cycles @2 A g ⁻¹	12
Flower-like NiCo ₂ O ₄ on graphene foam	Electrodeposition	1402 1220	1 10	76.6% after 5000 cycles @5 A g ⁻¹	13
NiCo ₂ S ₄ nanoflakes on Ni foam	Solution method	2732 2200	1 10	85.2% after 3000 cycles @30 A g ⁻¹	14
NiCo ₂ S ₄ nanoflakes on C-cloth	Electrodeposition	1418	5	82.2% after 20000 cycles @5 A g ⁻¹	15
NiCo ₂ O ₄ @NiCo ₂ O ₄ nanocactus	Hydrothermal/ Electrodeposition	1264 810	2 10	93.4% after 5000 cycles @1 A g ⁻¹	16
NiCo ₂ O ₄ -Ppy on C-textile	Hydrothermal/ polymerization	2244 1358	1 30	89.5% after 5000 cycles @3 A g ⁻¹	17
NiCo ₂ O ₄ @Ppy core-shell nanowires on C-microfiber	Hydrothermal/ Electrodeposition	2055 742	1 50	90% after 5000 cycles @4 A g ⁻¹	18
NiCo ₂ O ₄ @Ni ₃ S ₂ core/shell nanothorn	Hydrothermal/ Electrodeposition	1716 1104	1 20	83.7% after 2000 cycles @4 A g ⁻¹	19
NiCo ₂ O ₄ @NiCo ₂ O ₄ core-shell nanoarray	Hydrothermal	1917 1645	1 10	More than initial value after 2000 cycles @5 A g ⁻¹	20
NiCo ₂ S ₄ @MnO ₂ nanoheterostructure	Hydrothermal	1338 800	2 10	82% after 2000 cycles @20 A g ⁻¹	21
NiCo ₂ O ₄ nanosheets on Ni foam	Solution method	3184	1.2	69% after 2000 cycles @6 A g ⁻¹	This work
		1363	12		
NiCo ₂ O ₄ /NiCo ₂ S ₄ nanohybrids on Ni-foam		3542 2767	0.9 9		

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